

Supporting Information

Rigid Templating of High Surface-Area, Mesoporous, Nanocrystalline Metal Oxide Using a Polyether Block Amide Copolymer Template

Xingmao Jiang^{a, b} and C. Jeffrey Brinker^{a,c,d*}

^a Aerosol and Respiratory Dosimetry Program, Lovelace Respiratory Research Institute, Albuquerque, NM 87108, USA.

^bCenter for Micro-Engineered Materials, the University of New Mexico, Albuquerque, NM 87131, USA

^cSandia National Laboratories, MS 1349, Albuquerque, NM 87106, USA.

^d Departments of Molecular Genetics and Microbiology, The University of New Mexico, USA

*Corresponding Author: Sandia National Laboratories, MS1349, Albuquerque, NM 87106, USA. Fax: 01-505-272-7336; Tel: 01-505-272-7627; E-mail:cjbrink@sandia.gov

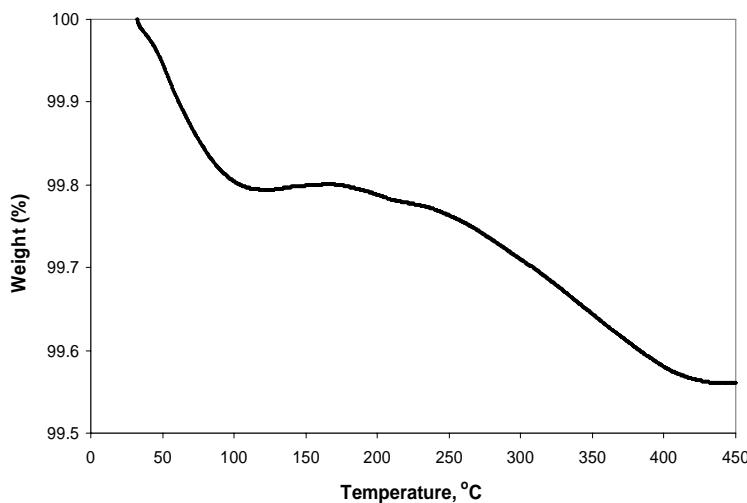


Figure S1. TGA analysis of washed rutile sample

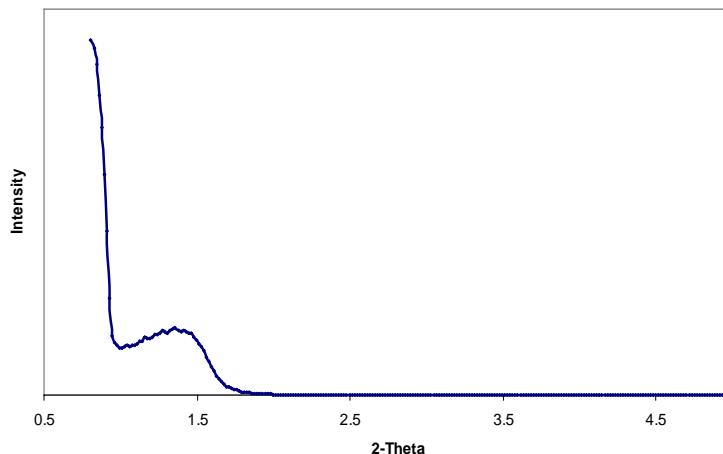


Figure S2. Low angle XRD for original undoped Pebax® 2533 film.

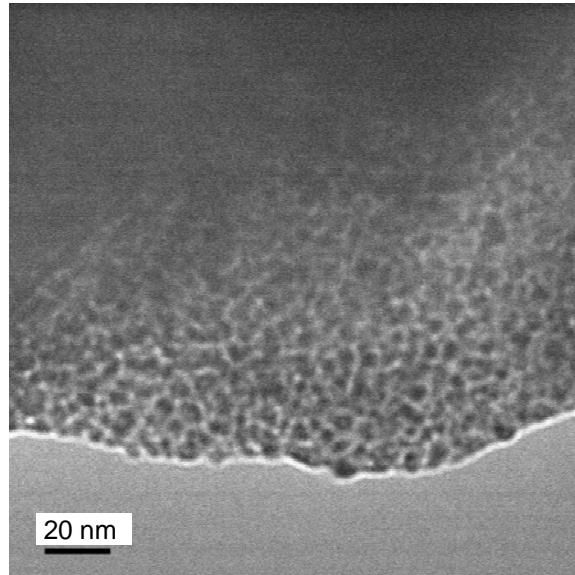


Figure S3. TEM image for PEBA film doped with Os salt.